

TESSERACT

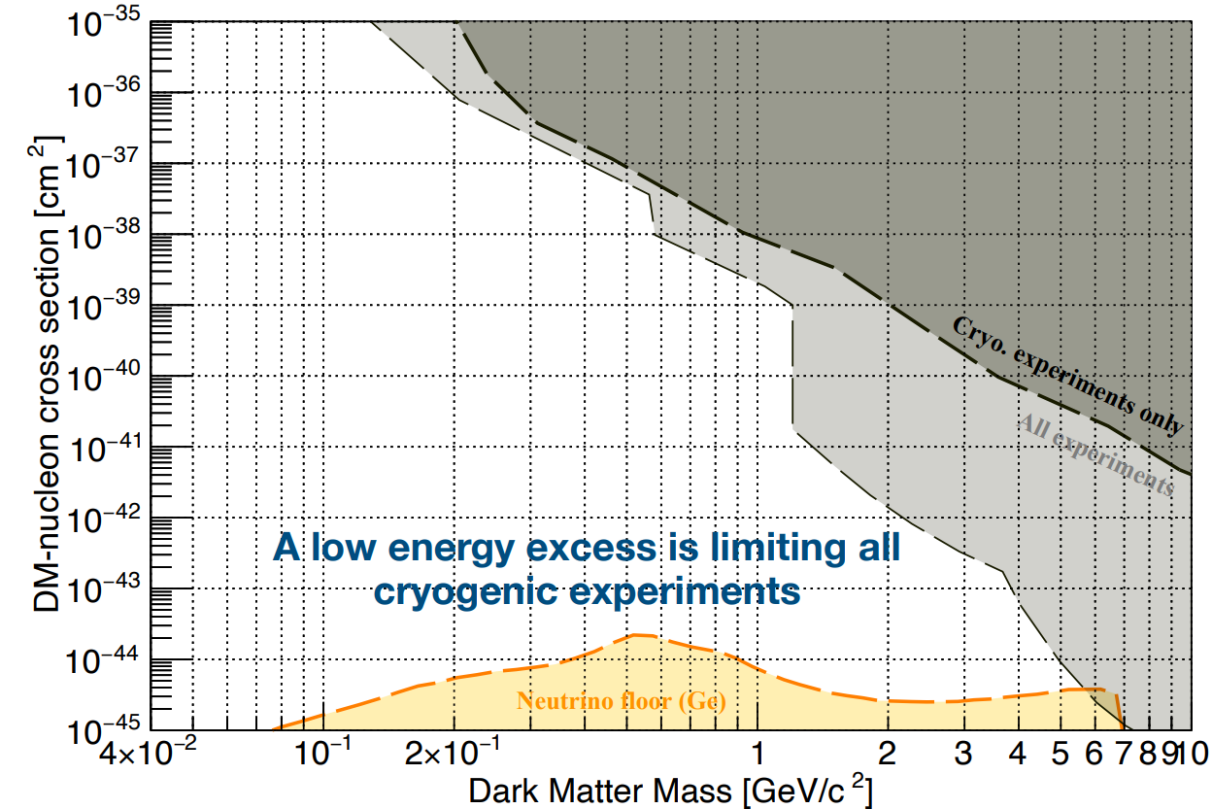
The TESSERACT Experiment at LSM: Ge Semiconductor Technology

Juliette Blé, LPSC Grenoble

Identification of Dark matter 2026

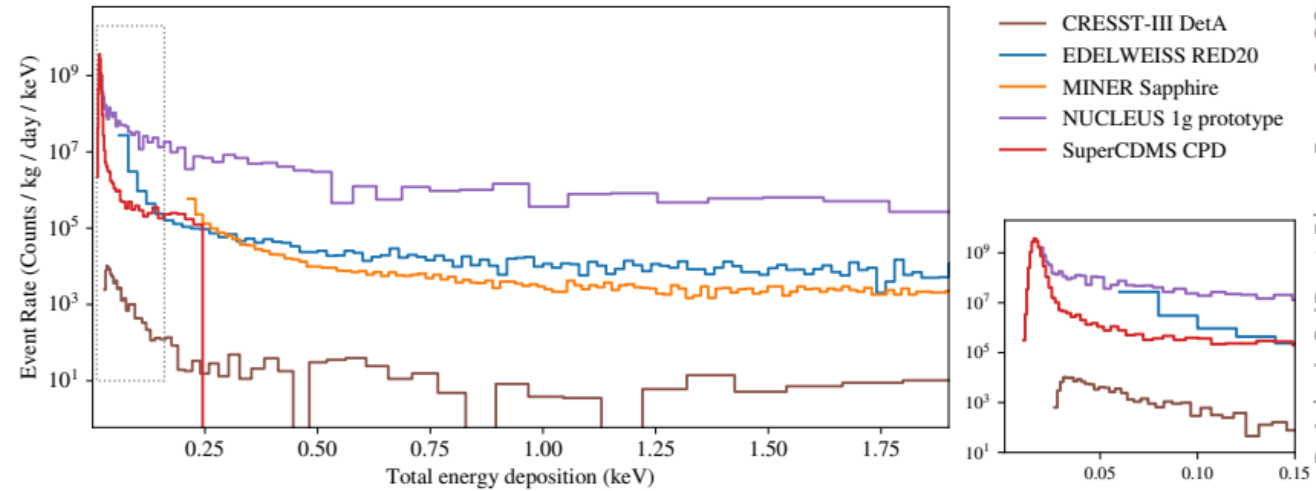
Low Energy Excess (LEE)

LEE is the dominating background at low energy



Design driver of TESSERACT:

- 1) Find the origin of LEE to mitigate it
- 2) Develop detector technologies with LEE rejection capabilities



LEE Characteristics:

- Non ionising
- Mostly independant of site
- Unknown origin

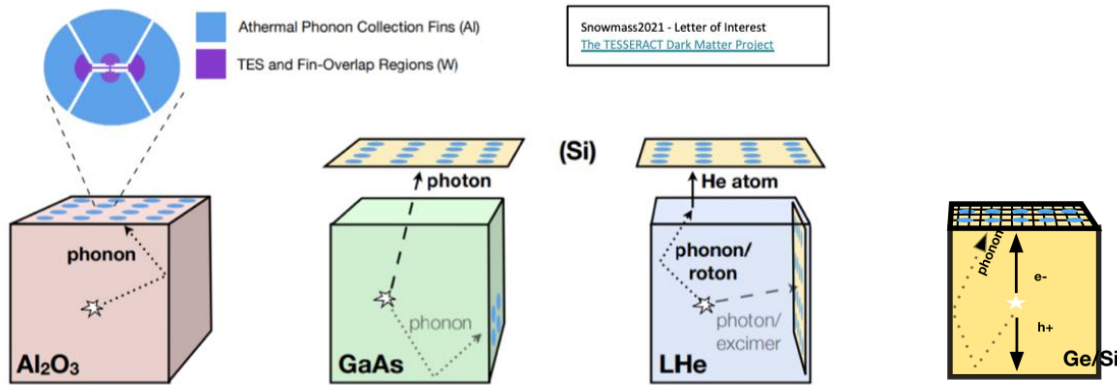


The Ge semiconductor technology for the TESSERACT experiment at LSM

The TESSERACT experiment

Transition Edge Sensor with Sub-Ev Resolution And Cryogenic Target

Goal: extending the Dark Matter mass search window from meV-to-GeV with ultra low-threshold cryogenic detectors with multiple targets and particle identification capabilities



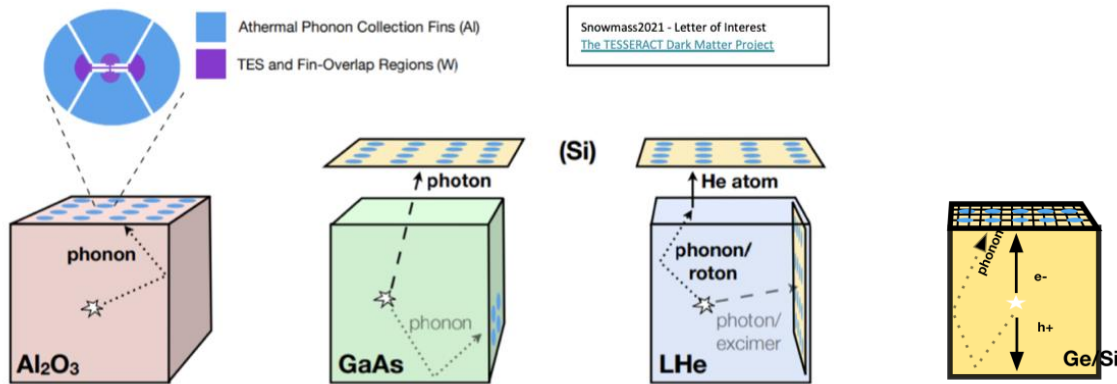
- One design, several targets leading to **different DM sensitivities**
- French additions to the initial proposal:
 - add the Ge/Si semiconductors calorimeter technology and benefit from RICOCHET and EDELWEISS experiences
 - Provide the experimental site in the deepest european laboratory **LSM**
- Integration of the full setup at LSM in 2028

The TESSERACT experiment

D. McKinsey talk on 06/04

Transition Edge Sensor with Sub-Ev Resolution And Cryogenic Target

Goal: extending the Dark Matter mass search window from meV-to-GeV with ultra low-threshold cryogenic detectors with multiple targets and particle identification capabilities



Snowmass2021 - Letter of Interest
[The TESSERACT Dark Matter Project](#)

S. Scorza talk on 06/02



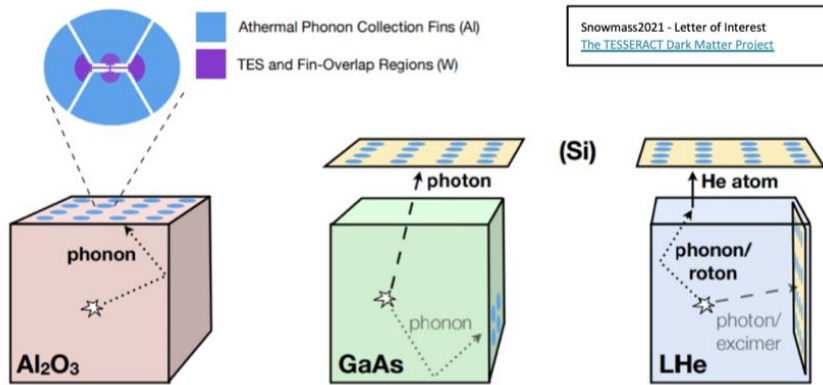
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The TESSERACT experiment

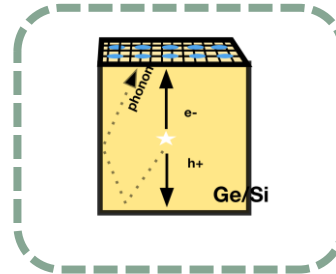
D. McKinsey talk on 06/04

Transition Edge Sensor with Sub-Ev Resolution And Cryogenic Target

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This talk

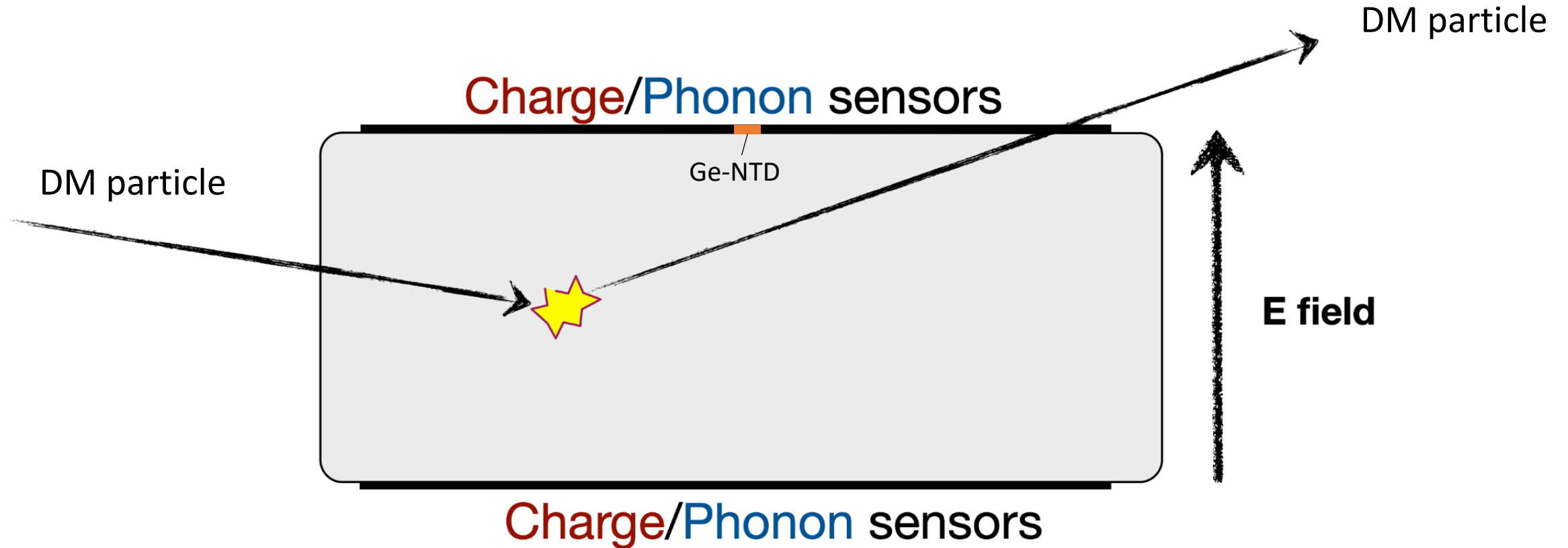


S. Scorza talk on 06/02

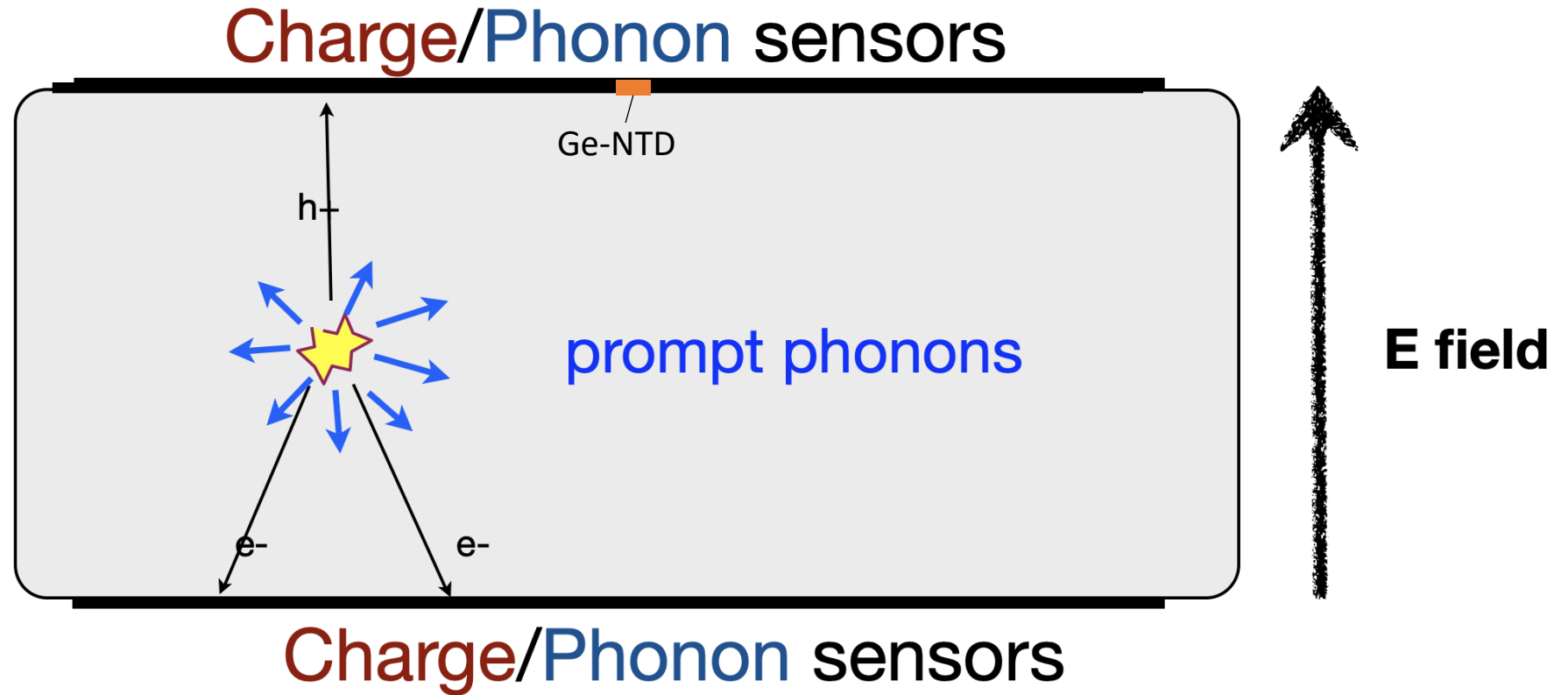


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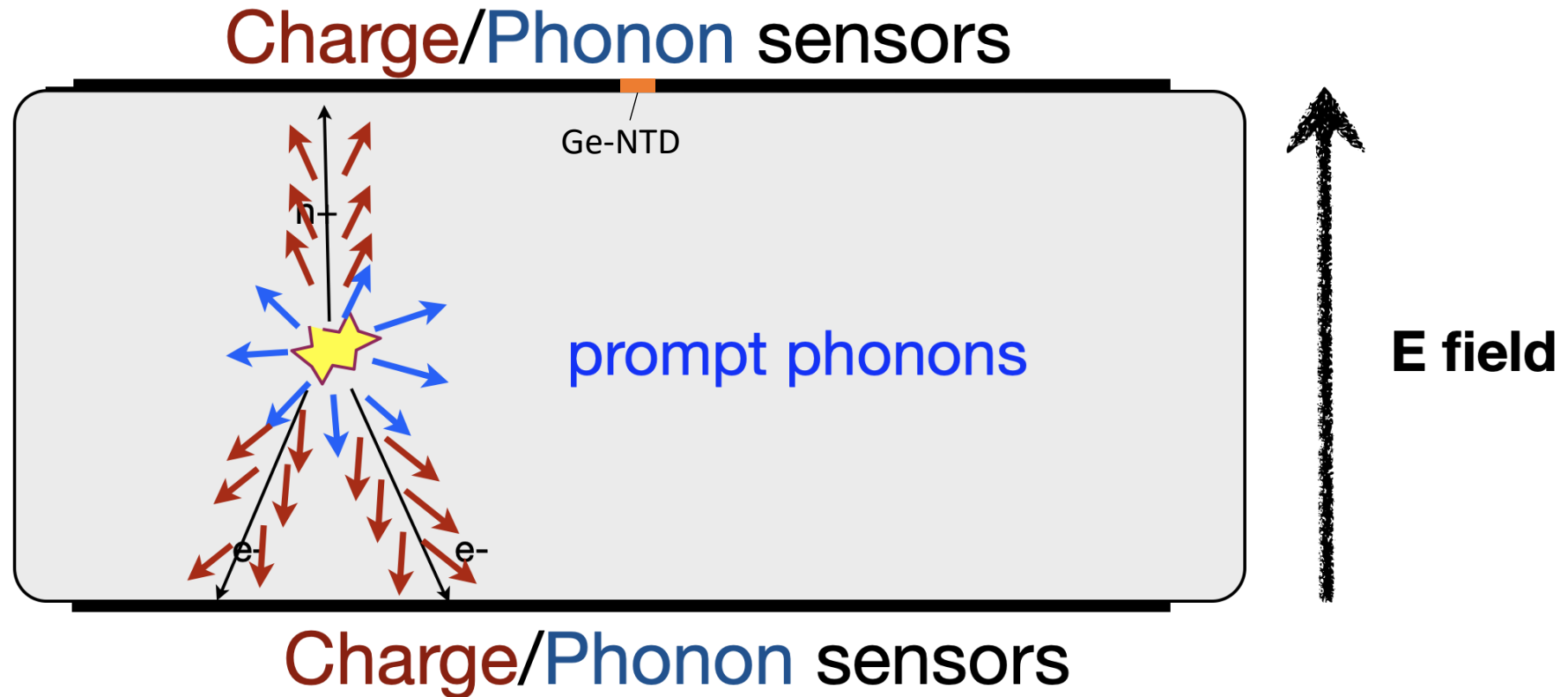
Dual phonon/charge detection



Dual phonon/charge detection



Dual phonon/charge detection



$$\begin{aligned} E_{total} &= E_{recoil} + E_{NTL} \\ &= E_{recoil} + \frac{1}{\epsilon_{Ge}} E_{ion} \Delta V \end{aligned}$$

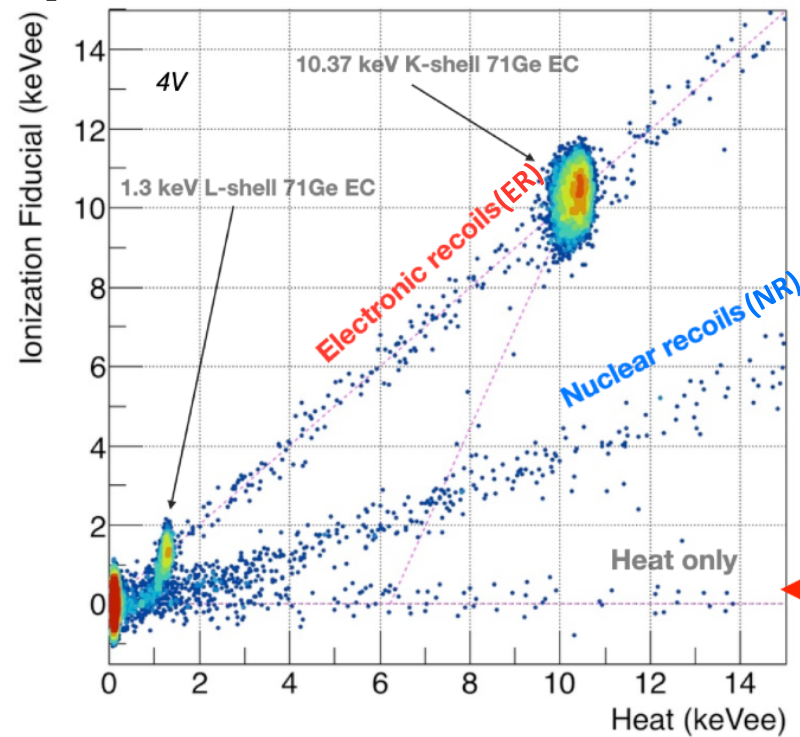
B. S. Neganov and V. N. Trofimov, Otkryt. Izobret.,
146, 215 (1985)

P. N. Luke, J. Applied Phys. 64,6858 (1988)

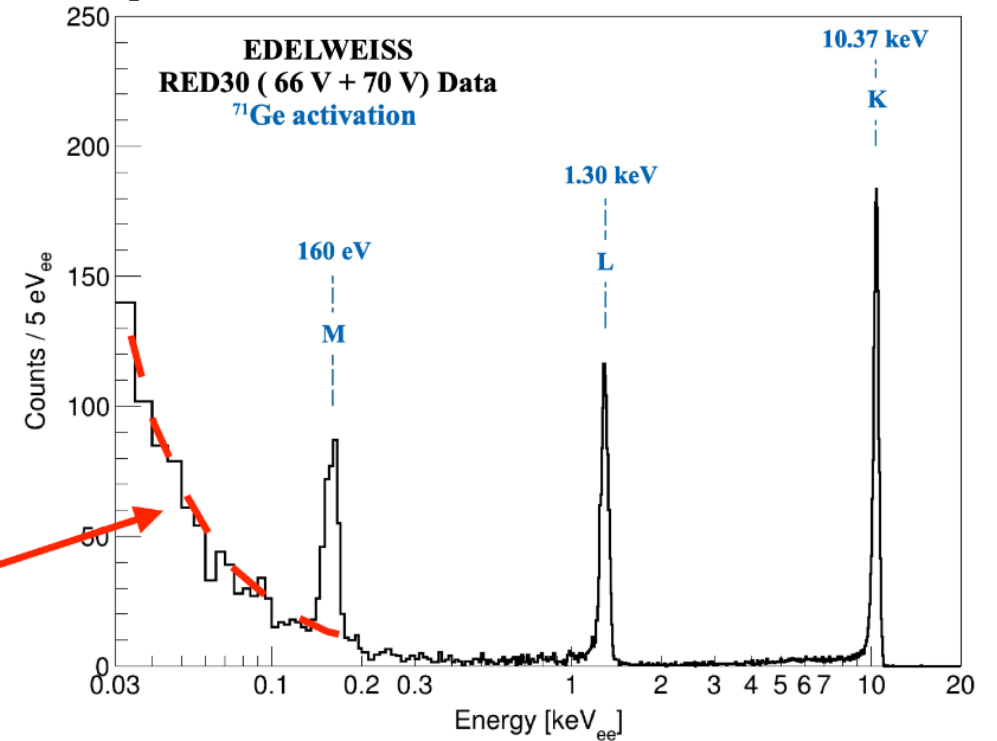
Low Voltage (LV) & High Voltage (HV) Mode

$$\begin{aligned} E_{total} &= E_{recoil} + E_{NTL} \\ &= E_{recoil} + \frac{1}{\epsilon_{Ge}} E_{ion} \Delta V \end{aligned}$$

Low Voltage mode ($\Delta V \sim 4V$)
Particle identification possible
Optimal for **NRDM**



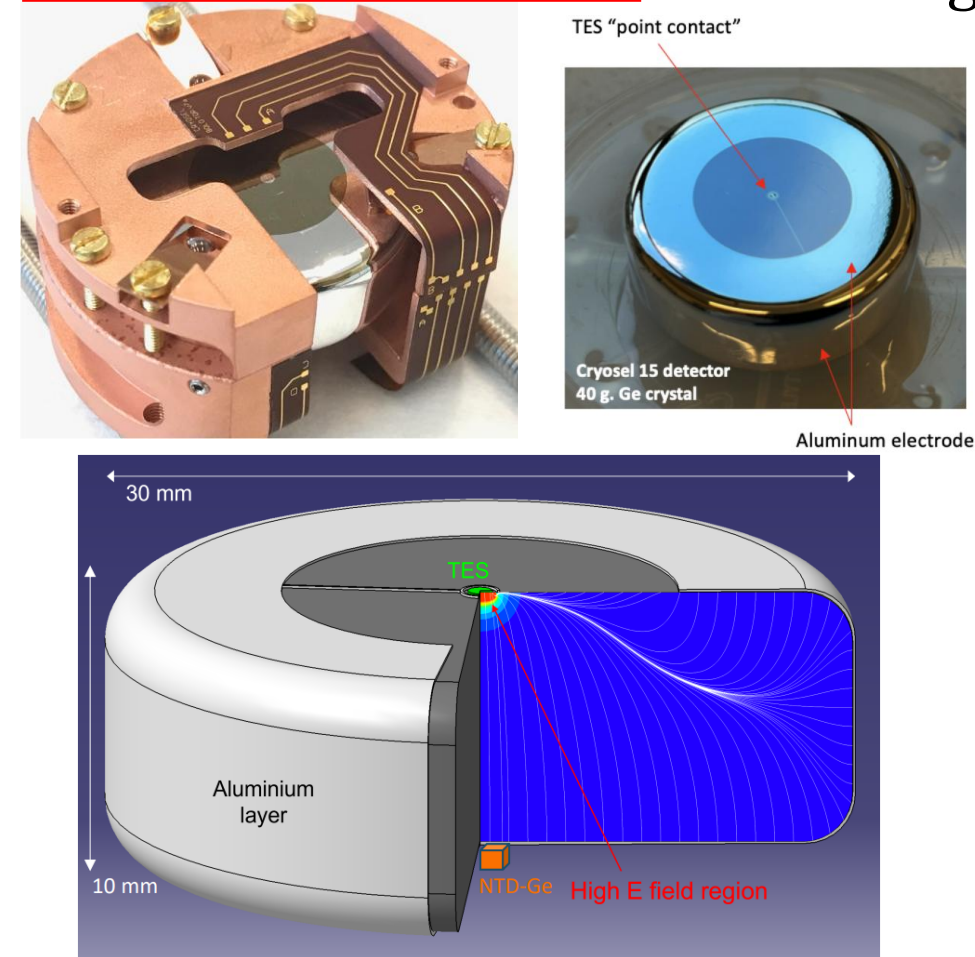
High Voltage mode ($\Delta V \sim 50V$)
Signal boosted, lower threshold
Optimal for **ERDM**



High Voltage Ge detectors

$$\begin{aligned} E_{total} &= E_{recoil} + E_{NTL} \\ &= E_{recoil} + \frac{1}{\epsilon_{Ge}} E_{ion} \Delta V \end{aligned}$$

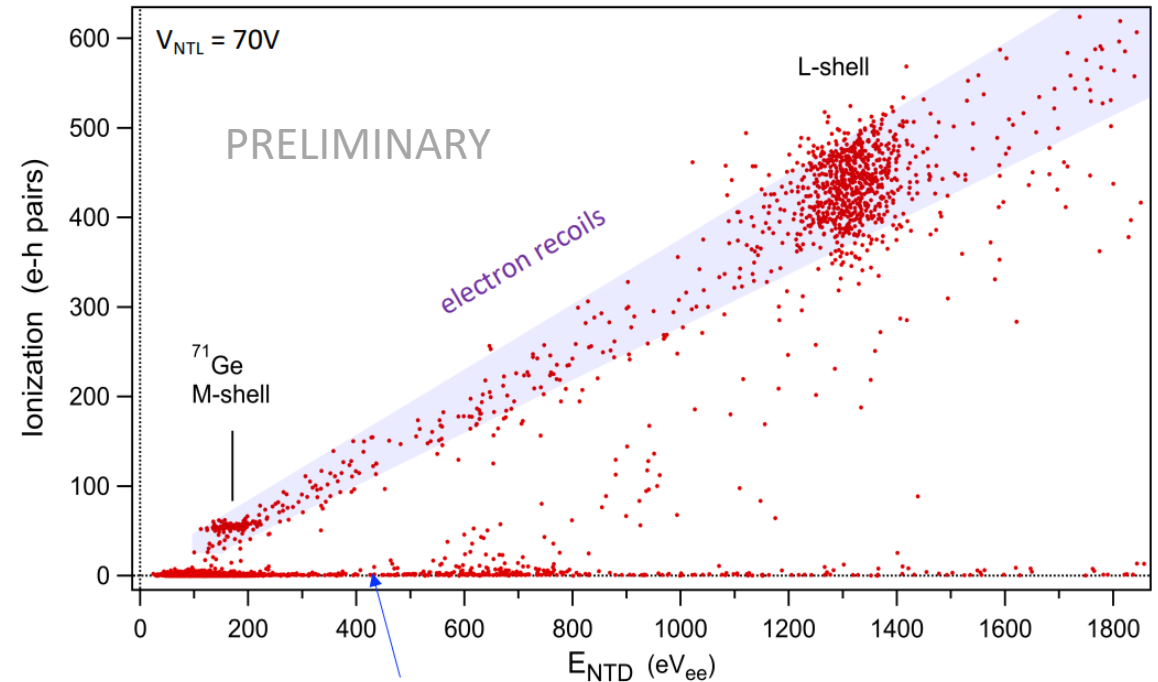
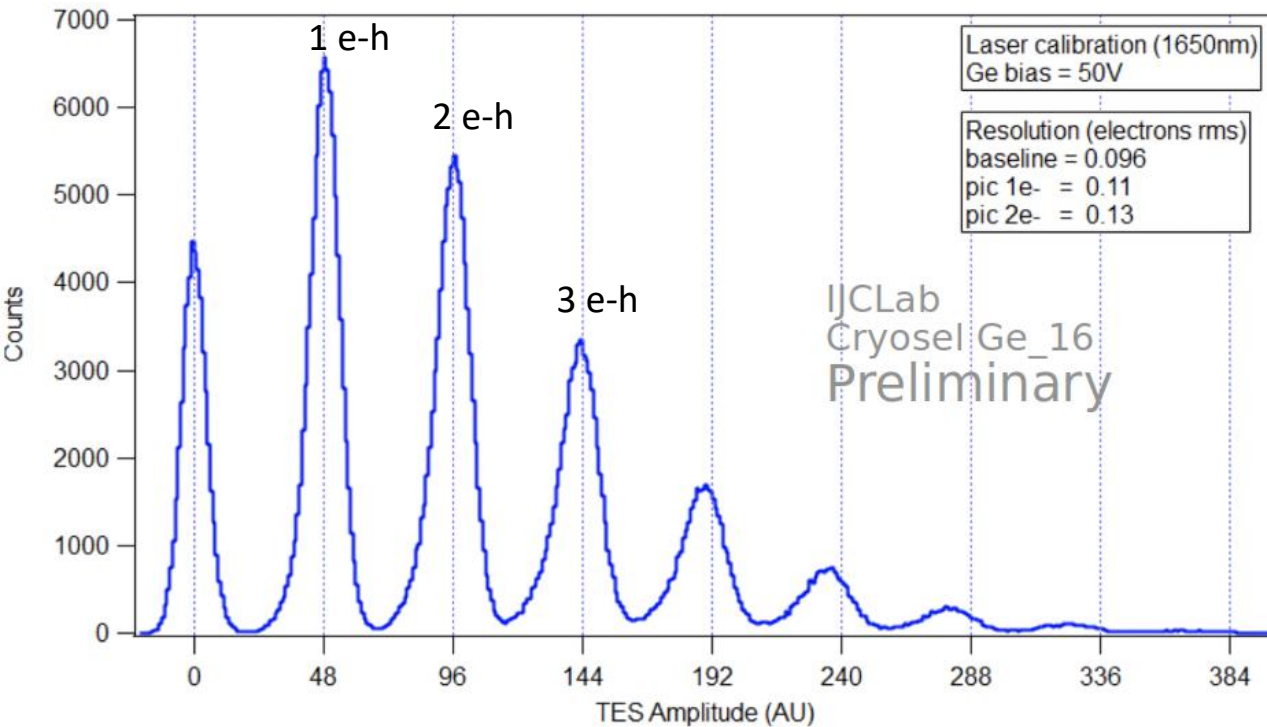
($\Delta V \sim 50V$) $\rightarrow$ amplification of ionization signal with NTL effect to reach single-electron sensitivity



- Large Al electrodes ($V_{NTL} \sim 50V$) + « point contact » TES ($V \sim 0V$)
 - $\rightarrow$ High electric field region
 - $\rightarrow$ Most of the NTL athermal phonons created in this region**Strong enhancement of the TES response**
- NTD-Ge glued at the bottom surface
 - $\rightarrow$ Measures the recoil energy $E_{NTL} + E_R$**Discrimination of non ionizing events (LEE discrimination)**

High Voltage Ge detectors

- First observation of a single-electron sensitivity in a massive (40g) Ge cryogenic detector
- Baseline resolution ~ 0.1 e-h pair

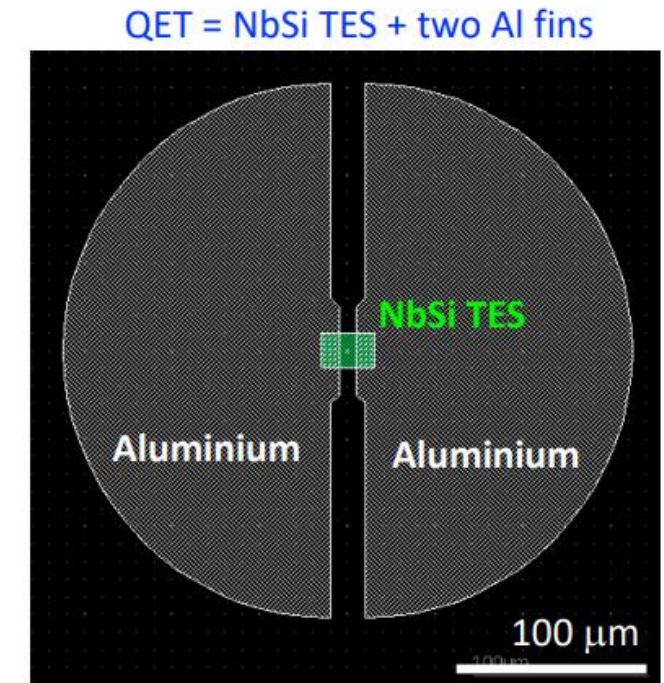


HO background + events with substantial trapping

- Clear separation of ER band and non-ionizing band
- Energy discrimination threshold limited by NTD-Ge sensitivity
- ER/NR identification in progress
- **Article in preparation!**

High Voltage Ge detectors: Future prospects

- Total payload of 4 x 40g Ge HV detectors
- Development of simulations for charge drift and athermal phonon propagation/collection efficiency
- Switch from NTD Ge to QET (Quasiparticle-trap-assisted Electrothermal-feedback TES sensors)
 - Phonon resolution $\sim 10\text{eV}$
 - Discrimination of ER/NR at low energy + LEE rejection

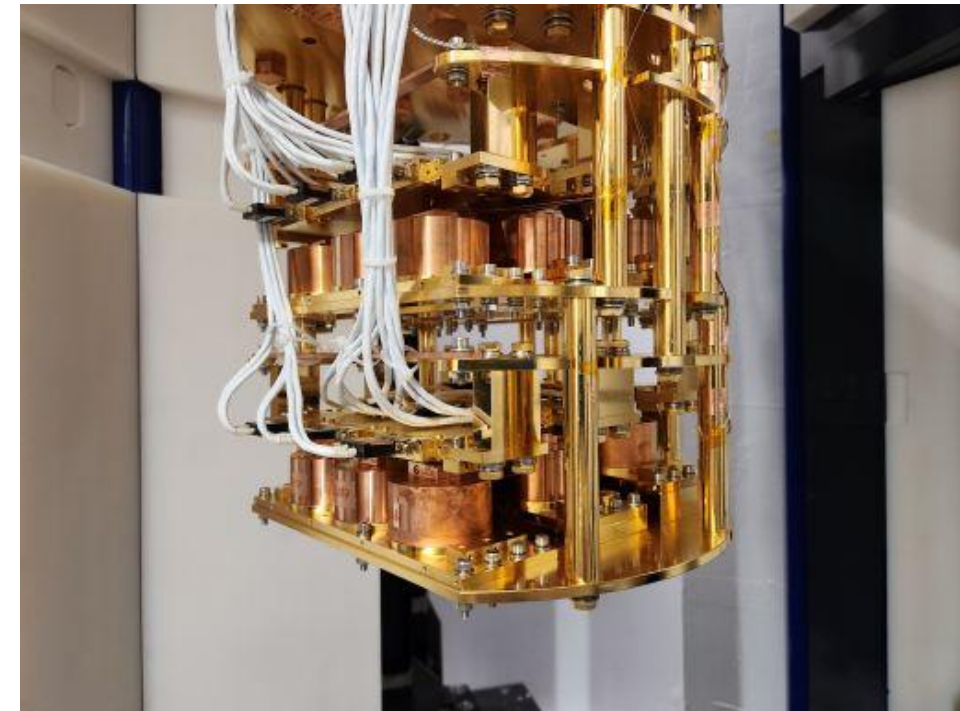


Low Voltage Ge detectors

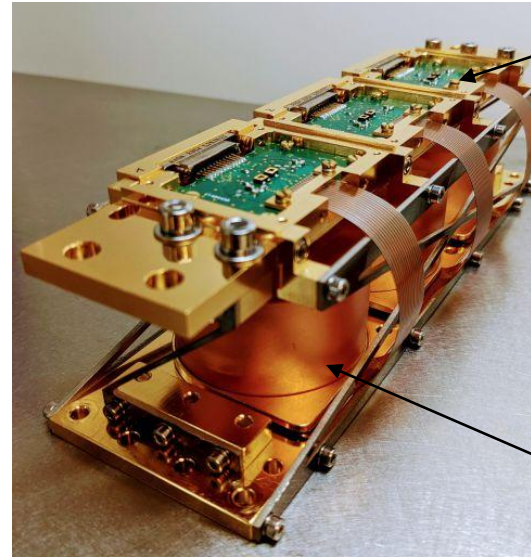
$$\begin{aligned} E_{total} &= E_{recoil} + E_{NTL} \\ &= E_{recoil} + \frac{1}{\epsilon_{Ge}} E_{ion} \Delta V \end{aligned}$$

($\Delta V \sim 4V$) $\rightarrow$ discrimination of NR/ER/LEE

State of the art from Ricochet



Ricochet cryostat at the Institut Laue Langevin



1K stage

10mK stage



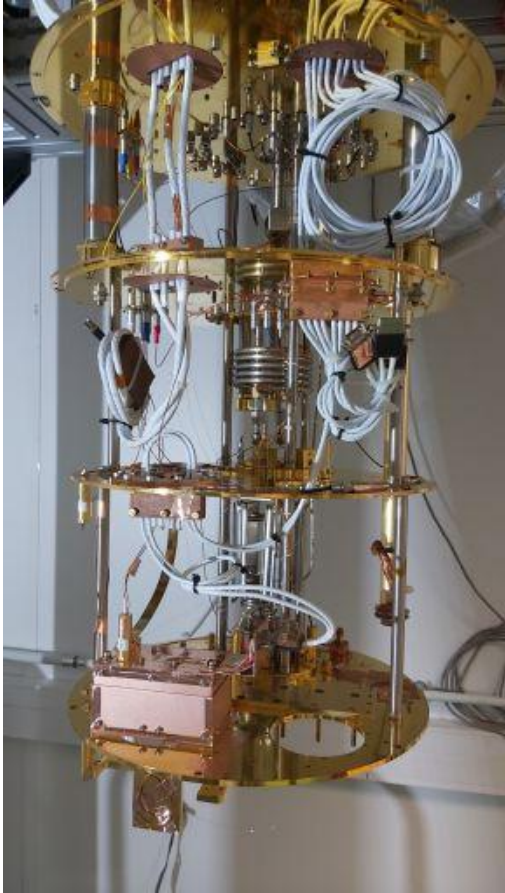
42g Ge detector

Phys. Rev. D 112, 112019

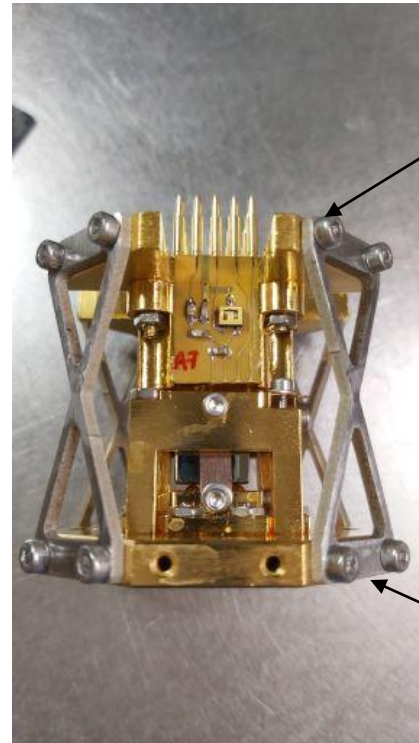
Ricochet commissioning performances:

- 18 x 42g Ge detectors
- Ionisation resolution ~ 40 eVee
- Phonon resolution $\sim 50 - 80$ eVph

Low Voltage Ge detectors

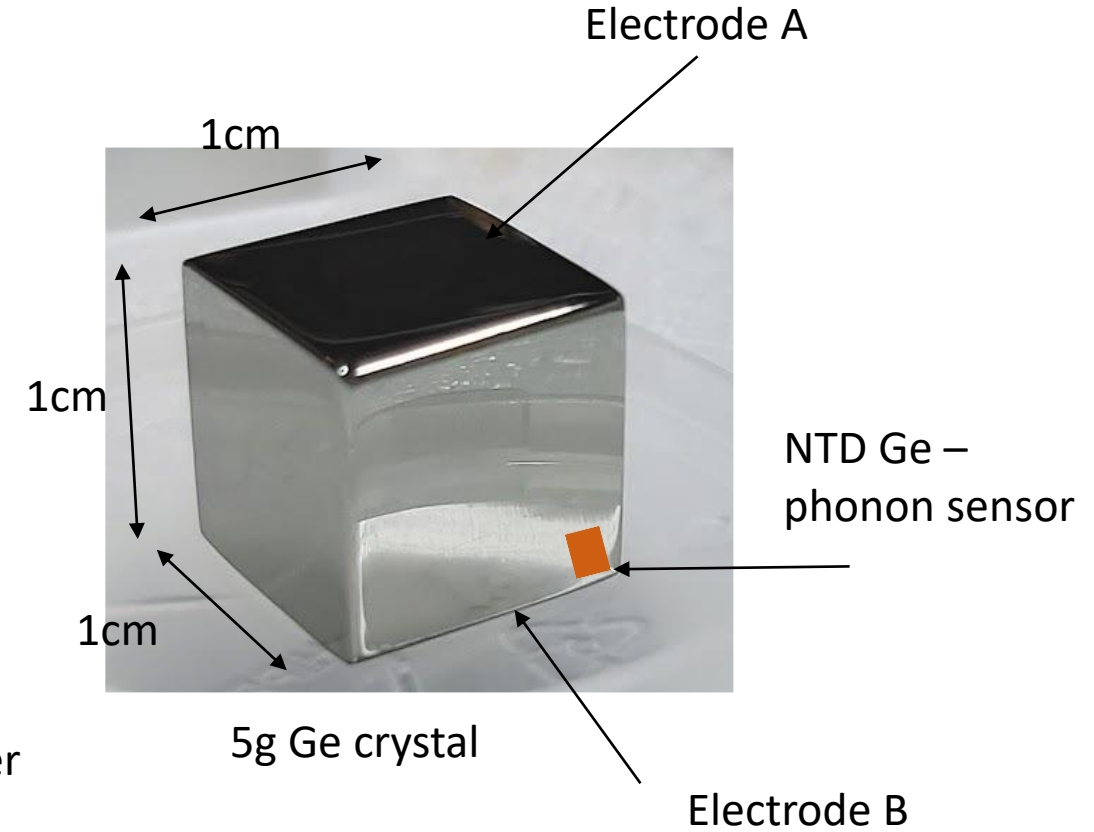


R&D cryostat at Lyon



100mK holder

10mK holder



Electrode A

1cm

1cm

1cm

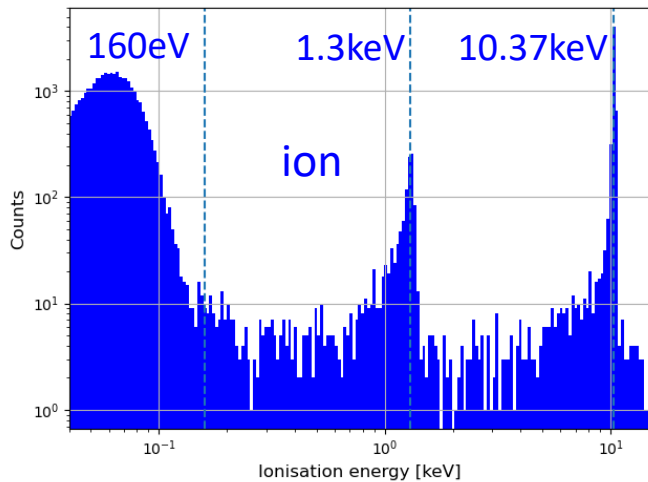
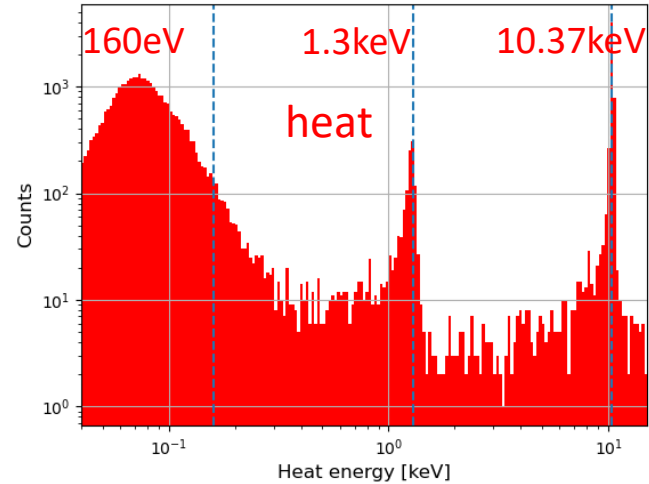
5g Ge crystal

NTD Ge –
phonon sensor

Electrode B

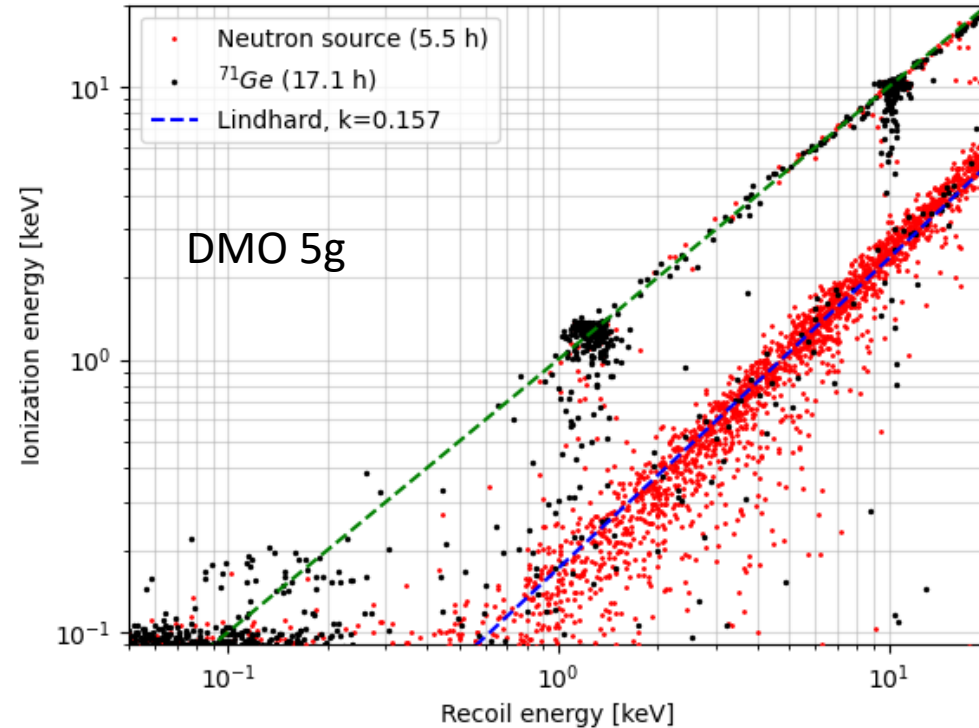
Low Voltage Ge detectors

Calibration using K,L,M shell of Ge71
after neutron activation



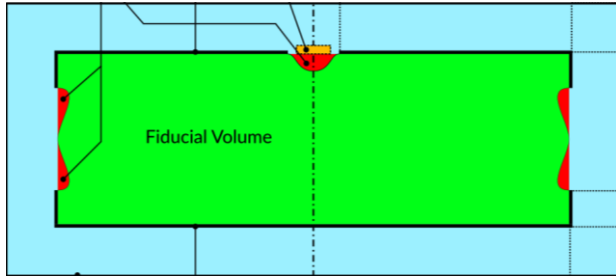
Tesseract Ge LV First prototype performances:

- 5g Ge detector
- Ionization resolution ~ 22 eVee
- Phonon resolution ~ 20 eVph
- Clear identification of NR/ER bands



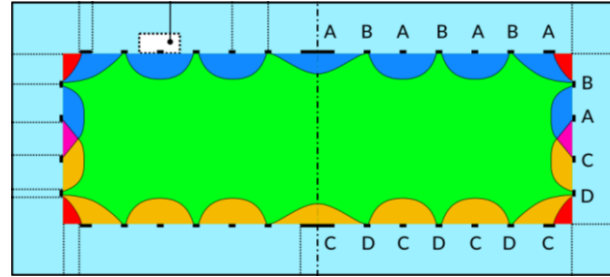
Low Voltage Ge detectors: Electrodes Geometry

Planar



Planar detector in Ricochet

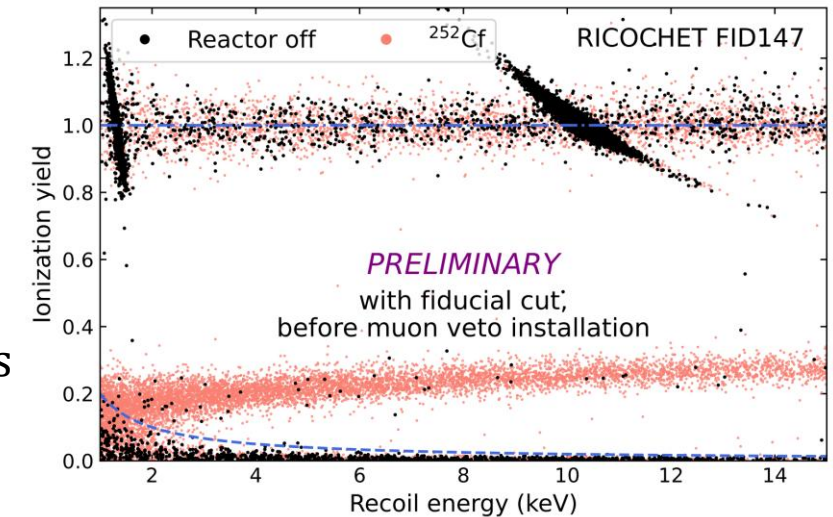
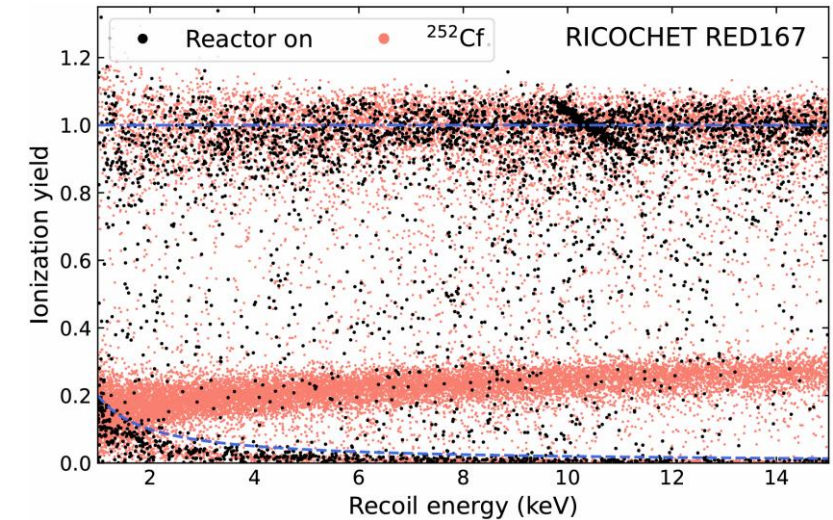
Fully Inter-Digitized (FID)



Fiducial detector in Ricochet

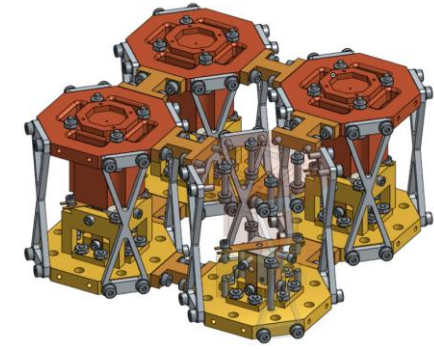
- **No surface event rejection**
- 2 fiducial electrodes
- Fiducial volume **100%**

- **Surface event rejection** possible
- 2 veto electrodes + 2 fiducial electrodes
- **Reduced** fiducial volume

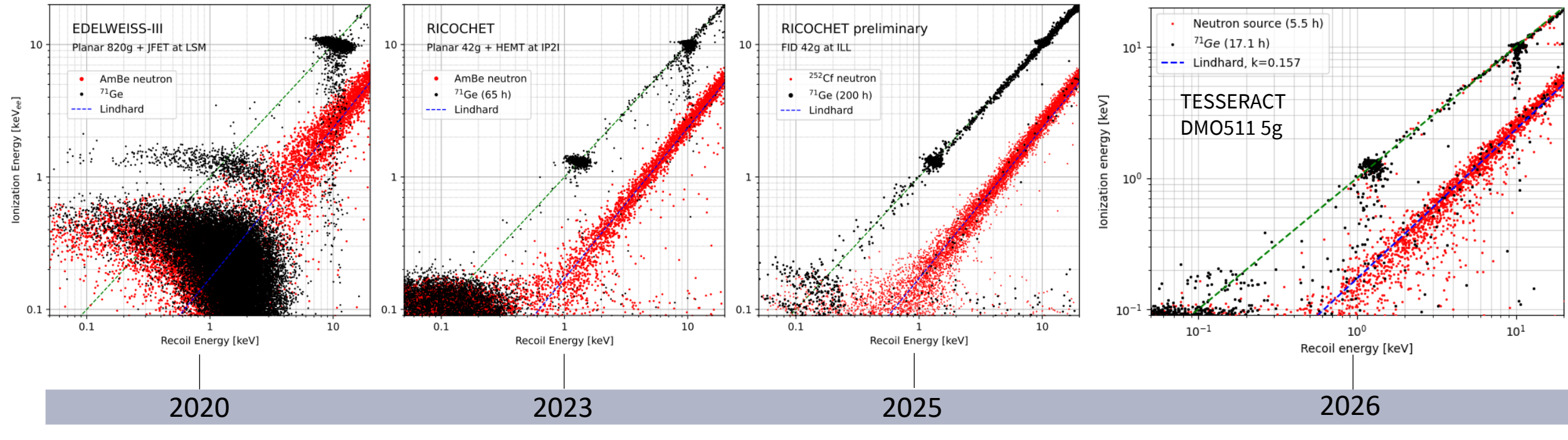


Low Voltage Ge detectors: Future prospects

- Total payload of 4 x 5g LV Ge
- Switch from NTD Ge to TES
- Resolutions goal: ionization < 10 eVee, phonon 100 meV
- ER/NR discrimination down to 100 eVnr



Total payload: 4 x 5.35 g



Conclusion

TESSERACT will allow for **different dark matter interaction** searches thanks to **multiple target** approach.

Semi-conductor program:

Low Voltage

- Optimal for NRDM
- Already proved ER/NR/LEE discrimination

High Voltage

- Optimal for ERDM
- Already demonstrated single electron-hole pair sensitivity

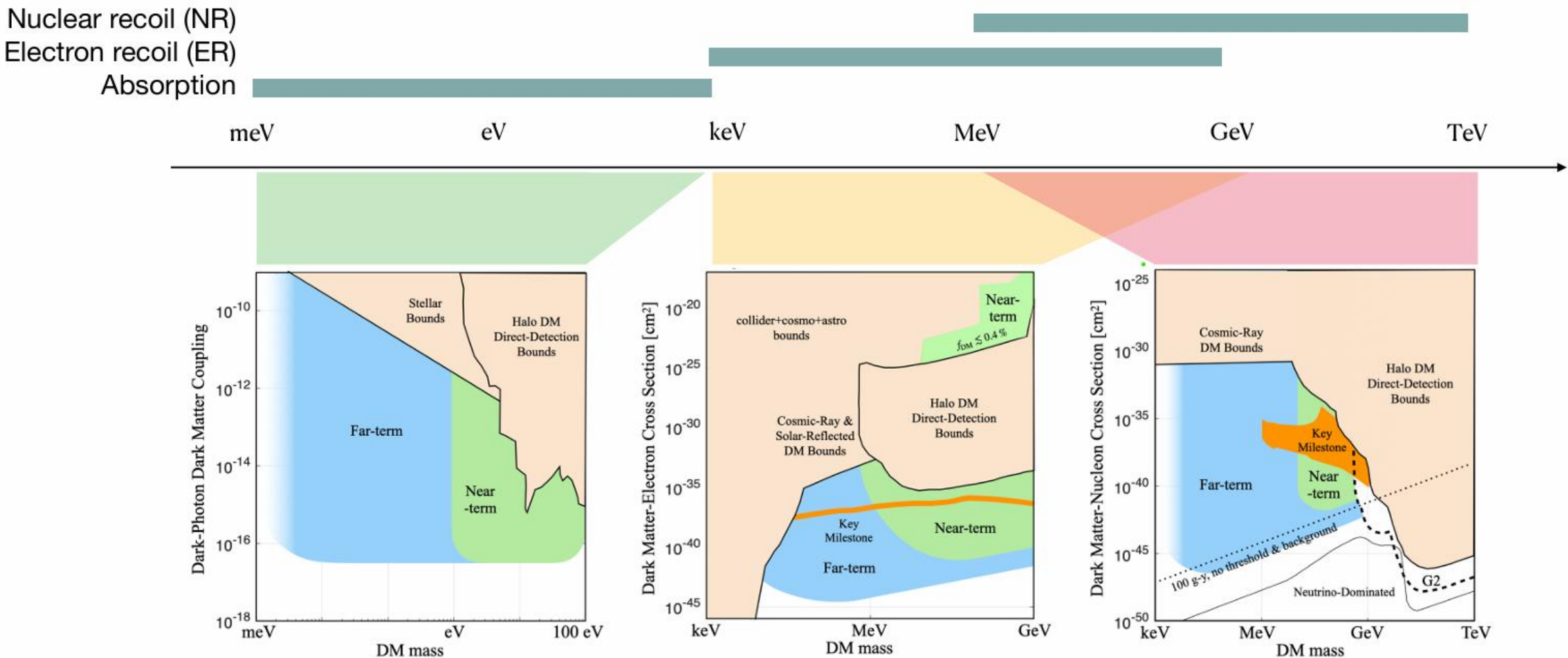
R&D work in progress to achieve exquisite performances

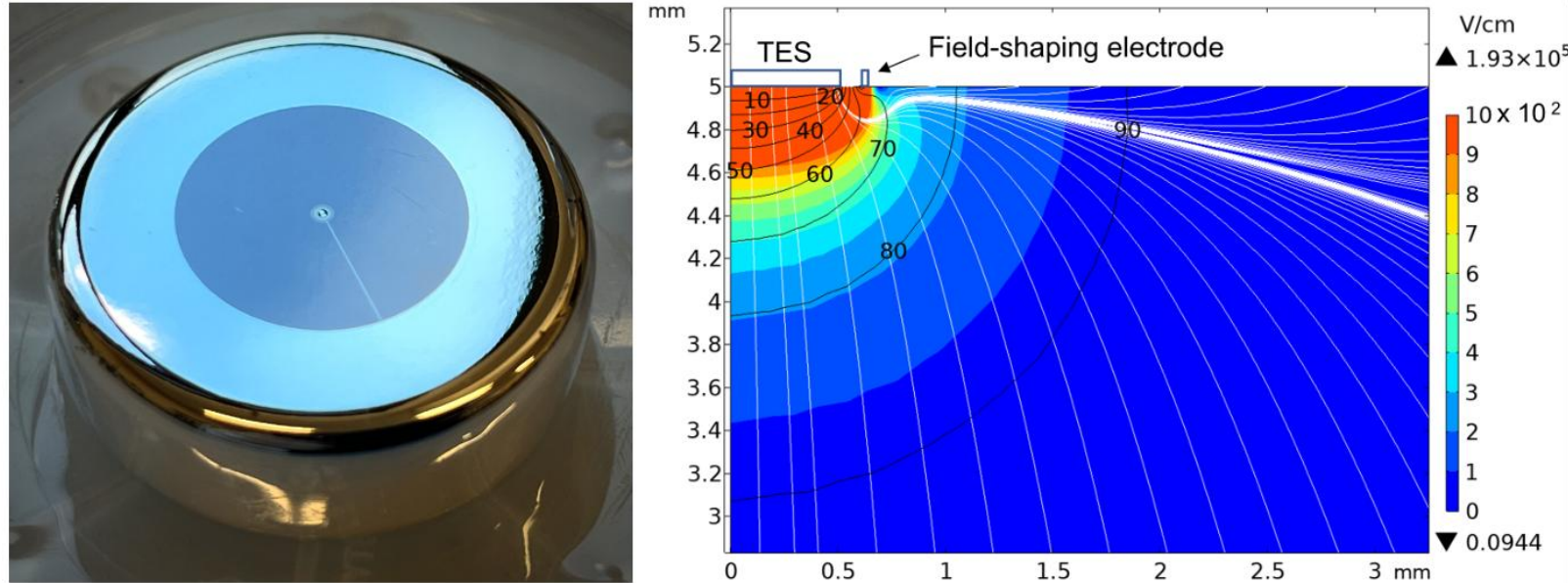
More on TESSERACT by D. McKinsey tomorrow



BACKUP slides

Looking for a wide range of DM masses

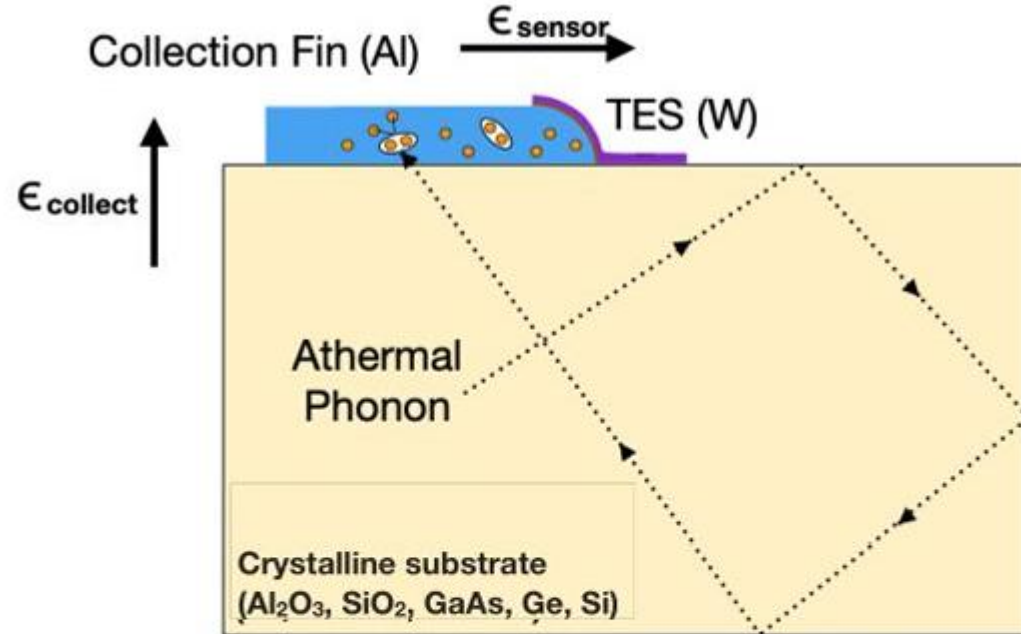




- TES = 50nm thick NbSi film
- Most of the NTL region are emitted in the red region (1-2 mm under the TES)
- TES measures the athermal phonons $E_{\text{NTL}} \rightarrow$ phonons from ionising events
- NTD measures $E_{\text{NTL}} + E_R \rightarrow$ phonons from ionising + non ionising events

E_{NTL} / E_R allows the discrimination of ER/NR/LEE

Transition Edge Sensors



$$\sigma_E \sim \frac{\sqrt{4k_b T_c^2 G (\tau_{\text{collect}} + \tau_{\text{sensor}})}}{\epsilon_{\text{collect}} \epsilon_{\text{sensor}}}$$

$$\sigma_E \propto V_{\text{det}}^{1/2} T_c^3$$

